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CONFIRMATION NO. 9247

23838
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FILING RECEIPT

Date Mailed: 01/30/2007

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Domestic Priority data as claimed by applicant

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Foreign Applications

JAPAN 2004-033132 02/10/2004
JAPAN 2004-092308 03/26/2004
JAPAN 2004-092309 03/26/2004

If Required, Foreign Filing License Granted: 01/26/2007

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US10/588,652**

Projected Publication Date: 05/10/2007

Non-Publication Request: No

Early Publication Request: No

Title

Polyester polymerization catalyst, polyester produced therewith and process for producing the polyester

Preliminary Class

528

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